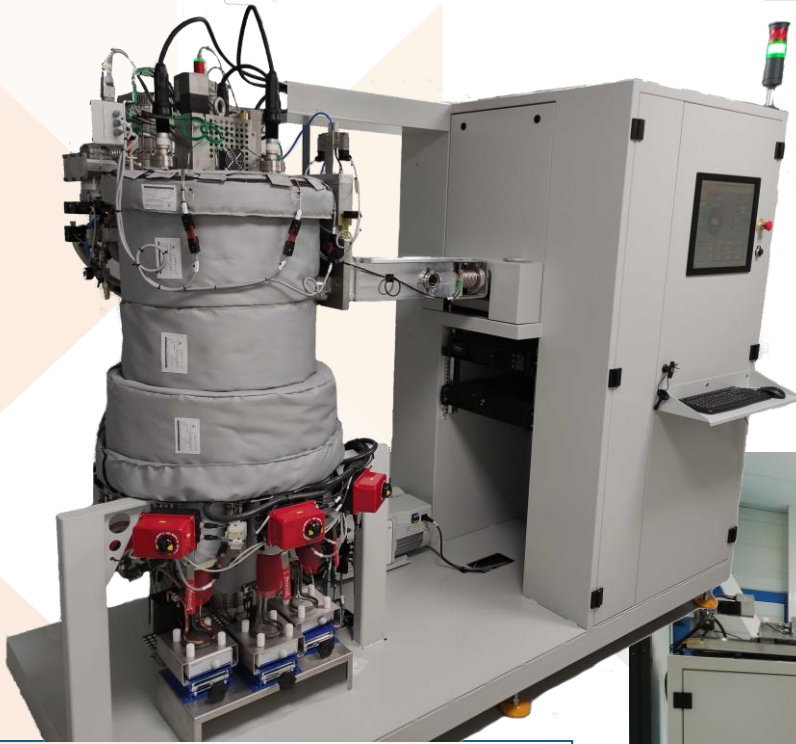


Oxides thin films Machines

3D-Oxides and Socrate Industrie have developed a comprehensive line of machines designed for the deposition of thin oxide layers. The complete Sybilla line, ranging from Ø150 to Ø450, meets all specific customer needs thanks to a variety of deposition capacities tailored to applications ranging from laboratory-scale to mass production, industrial applications, and R&D projects.

These machines use a technology called CBE. They incorporate reflectometry and RHEED, if needed. As a result, uniformity is excellent even on very large surfaces. For more information, please contact 3D-Oxides.



3D-Oxides SAS

41 Rue Henri Fabre
FR-01630 Saint-Genis-Pouilly
www.3D-Oxides.com
info@3d-oxides.com

Materials currently available:

TiO_2 (Titania)
 HfO_2 (Hafnia)
 ZrO_2 (Zirconia)
 Al_2O_3 (Alumina)
 SiO_2 (Silica)
 ZnO (Zinc Oxide)
 Ta_2O_5 (Tantalum pentoxide)
 VOx (various Vanadium oxides)
 Nb_2O_5 (Niobium pentoxide)
 LiNbO_3 (Lithium Niobate)
 LiTaO_3 (Tantalum Niobate)

